

Optical and Electrical Detection of Spin-Orbit Fields

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Fe/GaAs system Spin Orbit FMR Voltage control of spin orbit fields Optical detection of spin orbit fields





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: SFB 689 "Spin Phenomena in Reduced Dimensions" SFB 1277 "Emergent Relativistic Effects in Condensed Matter"

AvH foundation (Lin Chen)

Alexander von Humboldt Stiftung/Foundation

(interfacial) Spin Orbit Torques





Chernyshov et al., Nat. Phys. **5**, 656 (2009)

single crystalline material (GaMnAs) bulk polycrystalline material (Pt/Co/AlO_x) interface

Miron et al., Nature **476**, 189 (2011)

single crystalline material (NiMnSb) room temperature, bulk

Ciccarelli et al., Nat. Phys. (2016)

Spin Orbit Torques (Fields) at heavy metal (HM) ferromagnet (FM) interfaces



Spin Hall Effect (bulk)

$$T_{FL}$$
: field-like torque
 T_{DL} : (anti-)damping-like torque

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 $T_{FL} \sim m x (z x j_e)$ $T_{DL} \sim m \times [(z \times j_e) \times m]$ Inverse Spin Galvanic Effect (interface)

$$h_{\rm SOF} \sim \alpha J_{\rm e}$$

Bychkov-Rashba Rashba-Edelstein etc. (not bulk Rashba e.g. GeTe)

V.P Amin and M.D. Stiles, Phys. Rev. B 94, 104420 (2016)

A. Manchon et al., Rev. Mod. Phys. 91, 035004 (2019)

$$h_{\rm SOF} \sim \theta_{\rm SH} J_{\rm e}$$

(x,t) resolved detection of SOT induced switching process: Gambardella group





M. Baumgartner et al., Nat. Nanotech. 12, 980 (2017)

Experiments and micromagnetic simulations



To reproduce response by micromagnetic simulations, anti-damping like torque, field like torque, temperature and DMI must be taken into account

At low temperatures: deterministic domain wall nucleation from edges (and propagation) see Gambardella group

M. Decker et al., Phys. Rev. Lett. 118, 257201 (2017)

For current induced switching via Spin Orbit Torques, one would like to reduce the required current density J_e



Tuning Spin Hall Angles by Alloying, Phys. Rev. Lett. **117**, 167204 (2016)

L. J. Zhu et al. Phys. Rev. Appl. 10, 031001 (2018)



Possible modulation of SOI strength: electric field control



Problem: it is hard to control metals by electric field!



Thomas-Fermi screening length





Open question: can we use SCs to control a metal?

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Electric-field control of interfacial SOFs



- C_{2V} symmetry \Rightarrow Interfacial Bychkov-Rashba-like and Dresselhaus-like SOI
- SOI ~ $E_{in} = E_{bui} + E_{ext}$
- Allows electric-field control!

M. Gmitra, A. Matos-Abiague, C. Draxl, and J. Fabian, PRL **111**, 036603 (2013)

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Fe/GaAs system

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Fe/GaAs(001): crystal structure





- dangling bonds of As-atoms oriented along [1<u>1</u>0]
- fcc-GaAs and bcc-Fe:
 - \rightarrow lattice mismatch of 1.4 %
 - \rightarrow almost perfect epitaxial growth
- [110] and [1<u>1</u>0] directions **not** equivalent
- C_{2v} symmetry

Fe/GaAs(001): electronic band structure





- band structure calculated for 3 ML Fe / 9 ML GaAs(001)
- interface atoms determine spin character of bands
- Magnetization along [110] direction

M. Gmitra, A. Matos-Abiague, C. Draxl, and J. Fabian, PRL **111**, 036603 (2013)

- C_{2v} symmetry accounts for both, bulk inversion asymmetry and structure inversion asymmetry
- C_{2v} spin-orbit field lies in the plane of the slab, perpendicular to the growth direction.
- Effective magnetic field, direction and magnitude depend on the electron momentum:



e.g. well-known Dresselhaus SOF for zinc blende semiconductors and Rashba SOF in asymmetric quantum wells





M. Gmitra, A. Matos-Abiague, C. Draxl, and J. Fabian, PRL 111, 036603 (2013)



- Calculated SO coupling strengths for different energies and magnetization directions
- C_{2v} symmetry preserved for all energies
- Higher order contributions for higher energies



M. Gmitra, A. Matos-Abiague, C. Draxl, and J. Fabian, PRL 111, 036603 (2013)

In essence: anisotropic (C_{2V}) density of states at E_F



J. Moser *et al.*, Phys. Rev. Lett. **99**, 056601 (2007)

Crystalline AMR (CAMR) T. Hupfauer *et al.*, Nat. Commun. **6**, 7374 (2015) Anisotropic damping L. Chen *et al.* Nature Phys. **14**, 490 (2018)





data from S. Mizukami *et al*. Jpn. J. Appl. Phys. **40**, 580 (2001), Y. Tserkovnyak *et al*. PRB **66**, 224403 (2002)

Spin Pumping and SGE



M. Obstbaum *et al.* Phys. Rev. B **89**, 060407(R) (2014)

ТЛ

Spin-to-Charge conversion at the Fe/GaAs interface





Angular dependence expected: $\mathbf{J}_{e} \sim \mathbf{n} \times \boldsymbol{\sigma}$

Spin galvanic effect (SGE): no NM conducting layer

L. Chen et al. Nat. Commun. 7, 13802 (2016)

ТШ

Fe/GaAs system

Spin Orbit FMR

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Bychkov-Rashba (like)andDresselhaus (like)"due to structure inversion asymmetry
(SIA) at the Fe/GaAs interface""due to bulk inversion asymmetry
(BIA) in the bulk-GaAs"



 $H_{\mathsf{R}} = \alpha_{\mathsf{BR}}(\sigma_x k_y - \sigma_y k_x) \qquad \qquad H_{\mathsf{D}} = \beta_{\mathsf{D}}(\sigma_x k_x - \sigma_y k_y)$

No net spin accumulation



Bychkov-Rashba (like) and "due to structure inversion asymmetry (SIA) at the Fe/GaAs interface" Dresselhaus (like)

"due to bulk inversion asymmetry (BIA) in the bulk-GaAs"



Spin Orbit FMR





GaMnAs bar



- $\mathbf{j}(t) \Rightarrow \mathbf{h}(t)$
- $\mathbf{h}(t) \Rightarrow \mathbf{M}(t) \Rightarrow \mathbf{R}(t)$

• $V \sim \mathbf{j}(t) \mathbf{R}(t)$

D. Fang et al., Nat. Nano. **6**, 413 (2011), H. Kurebayashi, Nat. Nano. **9**, 211 (2014)

Spin Orbit FMR at the Fe/GaAs interface





D. Fang et al., Nat. Nano. 6, 413 (2011)

Spin Orbit FMR: results



One device! Repeat for devices structured along different directions



Dresselhaus and Bychkov-Rashba contributions

 $\mu_0 h^{[100]} = -0.15 \ mT \ \mu_0 h^{[010]} = 0.28 \ mT$

L. Chen et al. Nat. Commun. 7, 13802 (2016)

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M. Gmitra, A. Matos-Abiague, C. Draxl, and J. Fabian, PRL **111**, 036603 (2013)

Electric field control of SOFs: Schottky barrier



ТΠ

Electric field control of SOFs (12.5 GHz)





Electric field control of SOFs



Rashba vs. Dresselhaus in-plane SOFs show linear dependence on V_G

[100]-oriented device



Electric field control of SOFs





Electric field control of SOFs





 $\Delta \varepsilon_{\rm SO}$ = 2 $\mu_{\rm B} |{f B}_{\rm eff}|$

 $\mathbf{B}_{\text{eff}} = \mu_{\text{B}}^{-1} \left(\beta k_x - \alpha k_y, \ \alpha k_x - \beta k_y\right)$

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Optical detection of spin orbit fields

Typical ferromagnetic resonance based techniques





STT-FMR (FM/NM bi-layer)



SOT-FMR (single crystalline FM)

Typical ferromagnetic resonance based techniques





L. Liu et al. Phys. Rev. Lett. 106, 036601 (2011)

D. Fang et al. Nat. Nanotech. 6, 413-417 (2011)

- Lineshape method
- Heavy metals, single crystalline ferromagnets, antiferromagnets,

topological materials, and transition metal dichalcogenides, etc...

Recent detailed discussion: Resolving Discrepancies in Spin-Torque Ferromagnetic Resonance Measurements: Lineshape vs. Linewidth Analyses, arXiv:2103.04172v1

Problem for electrical detection



Time and spatially resolved magneto-optic Kerr microscopy





Alternative detection method: time resolved Kerr microscopy





- MOKE: Magnetization modulates light polarization
- Polar MOKE configuration
- Sensitive to out-of-plane component of dynamic magnetization

- 120 fs/80 MHz pulses as probe to phase locked microwave pump
- Optically detected FMR

Recording of Snapshots in time/phase



2D scans:

 \rightarrow Images of the dynamic out-of-plane magnetization m_z

J. Stigloher et al., Phys. Rev. Lett. 117, 037204 (2016)



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Problem for electrical detection



Phase lag between the input current j_{in} and the driving current in SO material j^{FM}





- Problem: averages different lineshapes
- Problematic for highly resistive materials (e.g. BiSe/NiFe)
- Wrong estimation of SOFs

Open question: can we still determine SOFs by magnetization dynamics?



Idea: use spatially resolved method

Recording of linescans as a function of magnetic field: Mode structure





Formation of SSW due to lateral confinement



 $h_{\rm Z}^{rf}$ does not contribute to all-electrical measurements



Mode spacing ~ FMR linewidth

- Interference of nearest modes
- A chance to determine SOFs

Formation of standing spin wave: CPW driven



• *w* = 2.8 μm, *t* = 3.5 nm, in the gap of CPW

• Symmetric $h_{Oe} \rightarrow$ symmetric modes

Formation of standing spin waves: electric current driven



-2

-1

0

y (μm)



 φ_{lj} is the phase difference between the input current J_{in} and the laser pulses (controlled phase)

 $\mu_0 H (\text{mT})$

70

75

65

3rd

2 -

σ

-2 -

60

(mון) ע

- SSW pattern shifts from center point
- Emergence of 2^{nd} mode excited by $h_{rf}^{FM,z}$

2

Impossible to determine SOFs since φ_{i-m} is unkown

Determine SOF: phase independent approach













$$j = 1 \times 10^{11} \,\mathrm{Am^{-2}}$$

$$V_{\text{max}}^{[110]} = 1.2V_{\text{max}}^{[010]} = 1.7V_{\text{max}}^{[-110]}$$

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Determine SOF by SSW pattern



L. Chen et al. arXiv:2010.06960

- Electronic properties of Fe/GaAs(001) interface are dominated by C_{2v} symmetry
- Mutual conversion of spin and charge currents at Fe/GaAs(001) interface
- Voltage control of SOFs demonstrated
- The ferromagnetic layer can be very thick! (> 1 nm)
- Sizeable effects at a simple interface!
- Electrically detected ST-FMR: be careful about the phase
- A new approach to determine the SOF by SSW pattern
- Phase independent and self-calibrated
- Can be applied to FM/HM bi-layers

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Methods to determine interfacial/bulk SOI





Thank you for your attention!